



"RESPONSE UNDER 37 CFR 1.116-  
EXPEDITED PROCEDURE EXAMINING  
GROUP 1716"

DOCKET NO: 0039-7632-0X

IN THE UNITED STATES PATENT & TRADEMARK OFFICE

RECEIVED  
DEC 31 2003  
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IN RE APPLICATION OF :  
HIROYUKI YANO, ET AL. : EXAMINER: DEO, DUY VU NGUYEN  
SERIAL NO: 09/531,163 :  
FILED: MARCH 17, 2000 : GROUP ART UNIT: 1765  
FOR: AQUEOUS DISPERSION, :  
AQUEOUS DISPERSION FOR  
CHEMICAL MECHANICAL POLISHING  
USED FOR MANUFACTURE OF  
SEMICONDUCTOR DEVICES, METHOD  
FOR MANUFACTURE OF  
SEMICONDUCTOR DEVICES, AND  
METHOD FOR FORMATION OF  
EMBEDDED WIRING

AMENDMENT AND REQUEST FOR RECONSIDERATION

COMMISSIONER FOR PATENTS  
ALEXANDRIA, VIRGINIA 22313

SIR:

Responsive to the Office Action of October 2, 2003, Applicants respectfully request reconsideration of the above-identified application in view of the following amendment and remarks.

**Amendments to the Claims** are reflected in the listing of claims which begins on page 2 of this paper.

**Basis for the Amendment** begins on page 7 of this paper and includes an attached replacement sheet.

**Request for Reconsideration** begins on page 8 of this paper.